

Supporting Information

Long-Term Stable 2H-MoS₂ Dispersion: Critical Role of Solvent for Simultaneous Phase Restoration and Surface Functionalization of Liquid-Exfoliated MoS₂

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Figure S1. (a) Photographs showing the dispersion stability of ce-MoS₂ in polar solvents after 1 week. (b) Boiling point and surface tension data of polar solvents used in this study

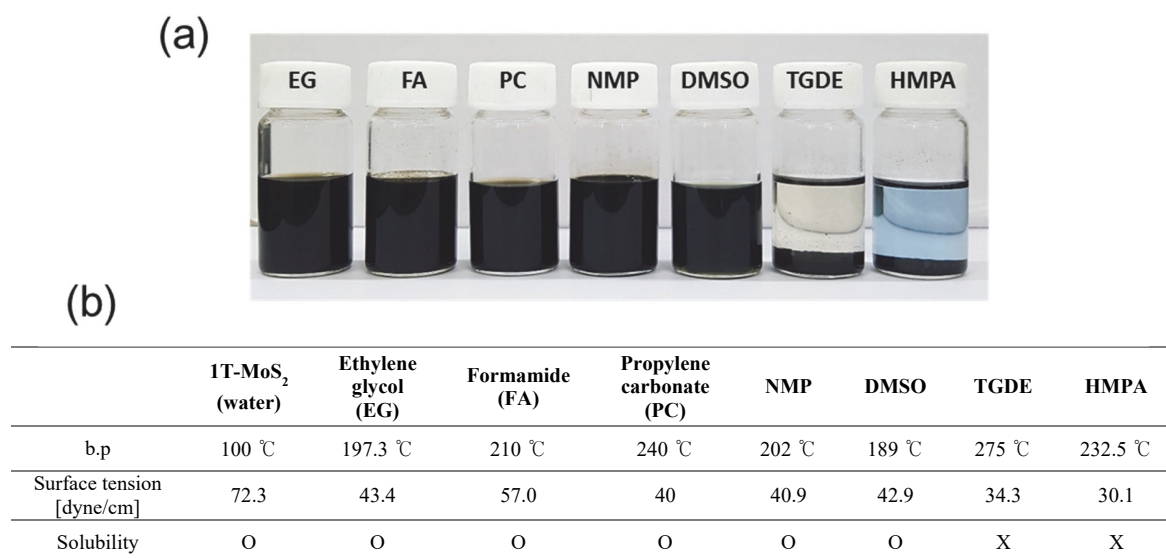


Table S1. The molar ratio of 1T-MoS₂, 2H-MoS₂, and MoO₃ calculated from the Mo 3d and S 2p XPS.

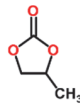
Solvent						
	1T-MoS ₂ (water)	Ethylene glycol	Formamide	NMP	Propylene carbonate	DMSO
Mo ⁺⁴ (1T)	62.38 %	17.91 %	19.11 %	17.62 %	16.80 %	19.05 %
Mo ⁺⁴ (2H)	26.27 %	70.61 %	68.04 %	75.18 %	71.98 %	72.02 %
Mo ⁺⁶ (MoO ₃)	11.35 %	11.47 %	12.85 %	7.20 %	11.22 %	8.93
2H/(1T+2H) - Mo base	29.63	79.76	78.07	81.01	67.96	69.01
S ⁻² (1T)	78.75 %	14.96 %	14.34 %	12.88 %	15.44 %	13.85 %
S ⁻² (2H)	21.25 %	85.04 %	85.66 %	87.12%	84.56 %	86.15 %

Figure S2. High-resolution O 1s XPS spectra for ce-MoS₂, MoS₂-NMP, MoS₂-PC, MoS₂-FA, MoS₂-EG, and MoS₂-DMSO.

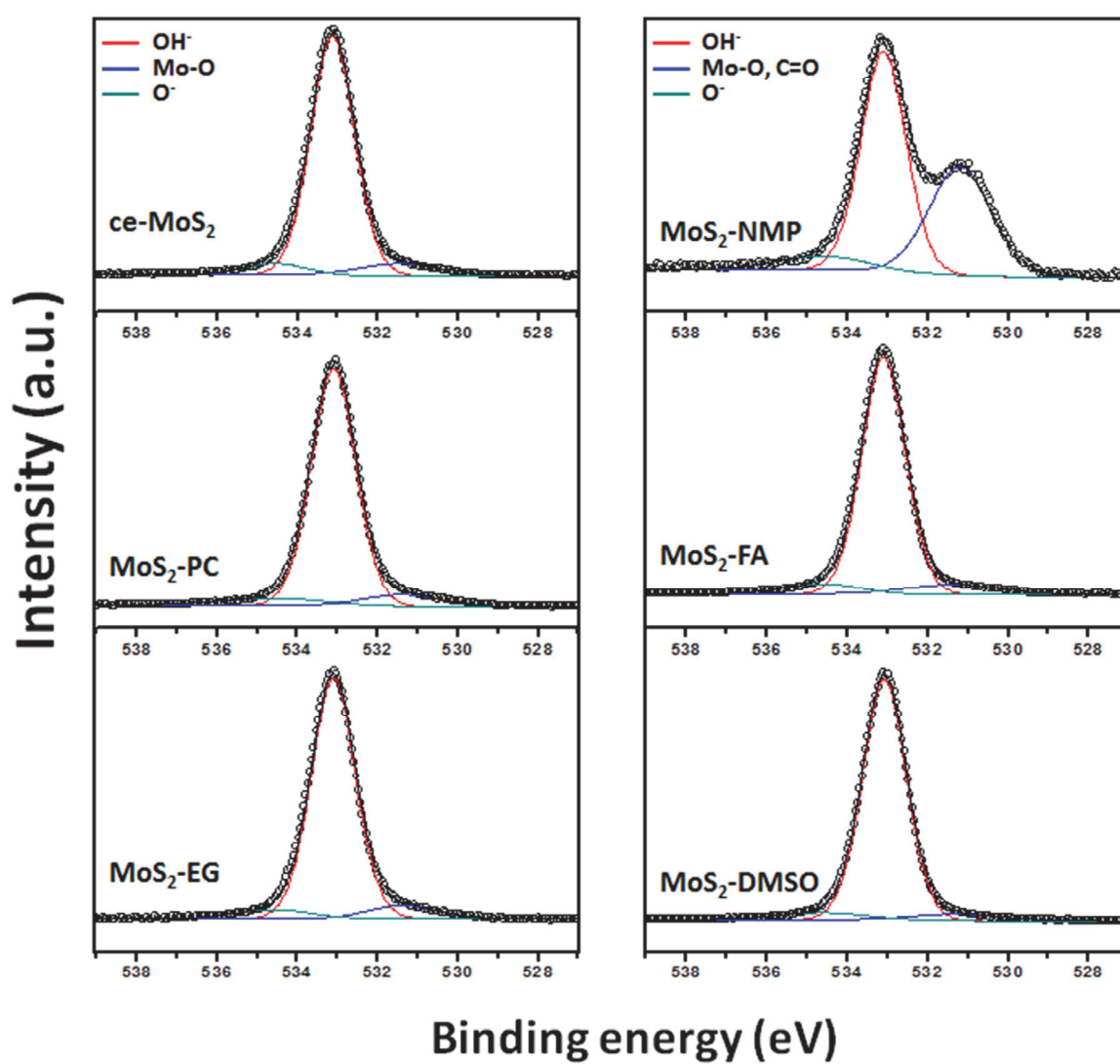


Figure S3. (a) S 2p XPS spectra of as-prepared ce-MoS₂ and after solvent thermal treatment in polar solvents at 180 °C for 5h. Red and blue lines represent the 2H-MoS₂ and 1T-MoS₂, respectively. (b) Calculated fraction of 2H phase after solvent thermal treatment in each polar solvent from the S 2p XPS analysis. The calculated phase transition yield is about 85%.

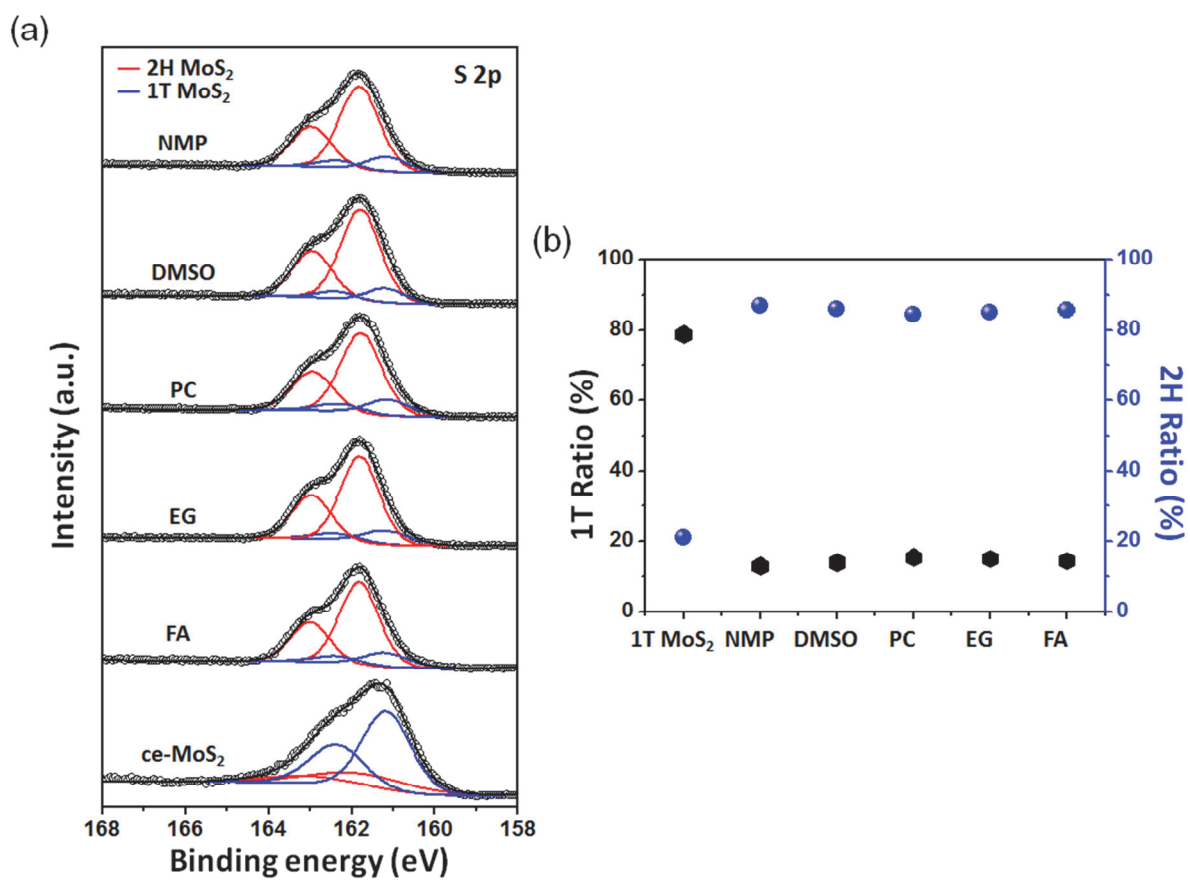
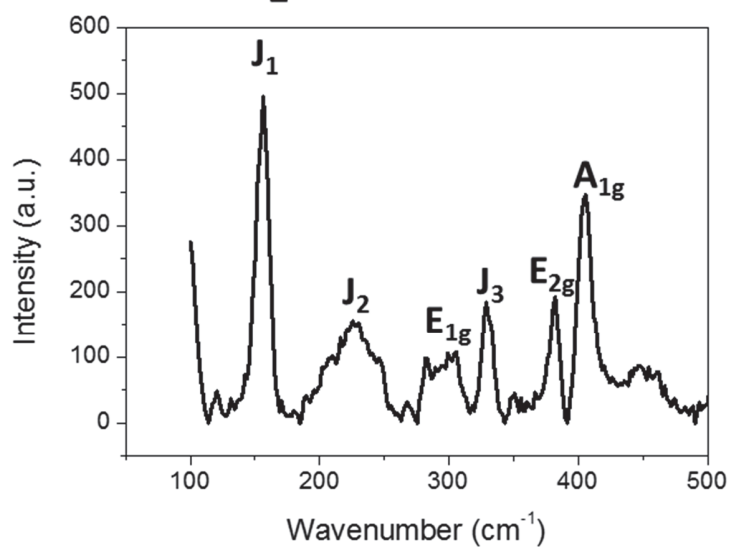


Figure S4. Raman spectra for (a) ce-MoS₂ and (b) MoS₂-NMP on Si substrate.

(a) ce-MoS₂



(b) MoS₂-NMP

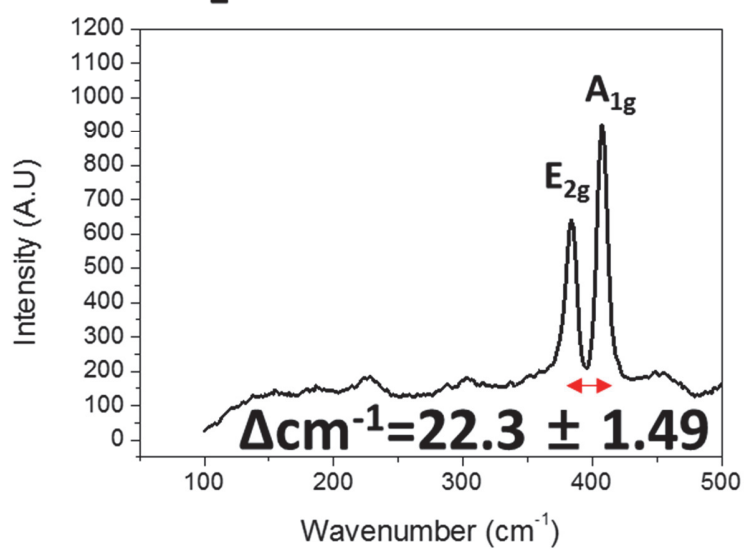


Table S2. Positions of A and B exciton peaks in the optical absorption spectra of 2H-MoS₂ after solvent thermal treatment. (In monolayer MoS₂, A exciton – 1.887 eV (657.01nm), B exciton – 2.042 eV (607.77nm))

Solvent	A exciton [nm]	B exciton [nm]	Δ A exciton (based on NMP)
1T	-	-	-
EG	660.2	611.6	+3.2
FA	659	611.2	+2
PC	658	609.4	+1
DMSO	659.8	610.6	+2.8
NMP	657	607.4	-

Figure S5. (a) AFM height topography of MoS₂-NMP flakes on Si substrate. (b) Height profile along the black and green lines in Figure S5a. (c) Height histogram and (d) diameter histogram of 50 different MoS₂-NMP flakes.

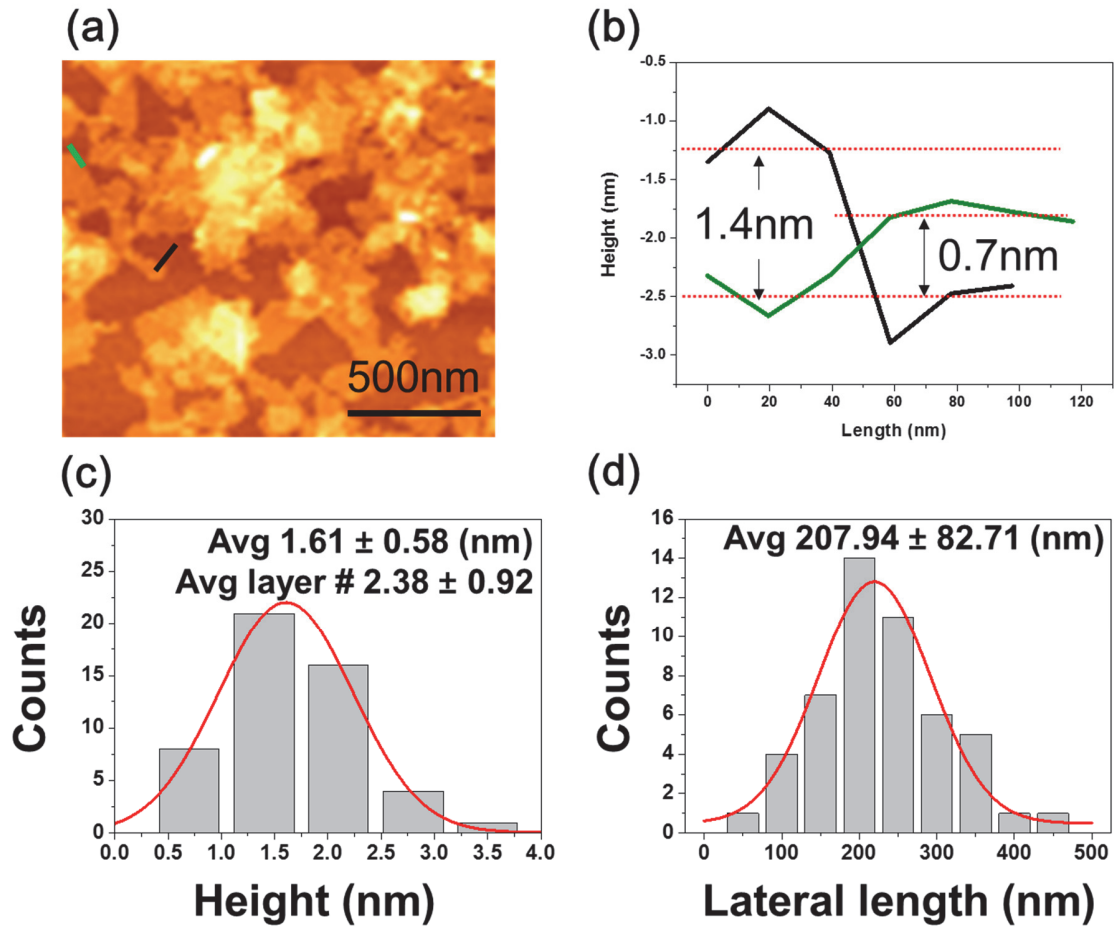


Figure S6. (a) AFM height topography of MoS₂-NMP flakes on Si substrate, which were stored for 10 months. (b) Diameter histogram of 50 different MoS₂-NMP flakes stored for 10 months.

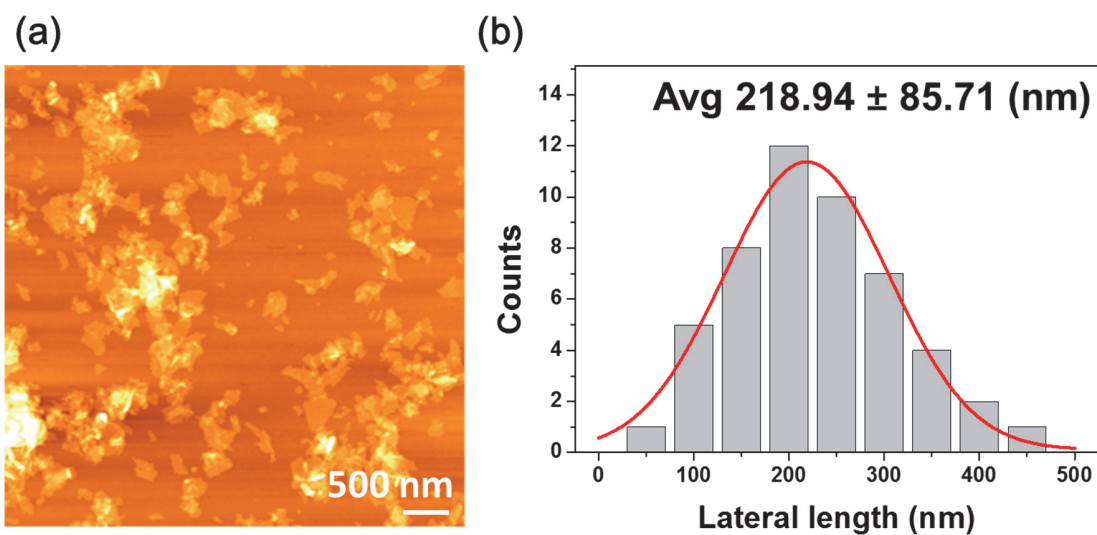


Figure S7. Photographs of pristine NMP and solvent-thermal-treated NMP at 180 °C for 5h.

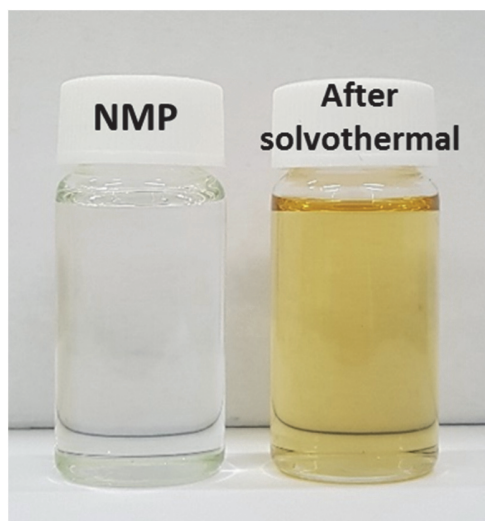


Figure S8. High-resolution C 1s XPS spectra for ce-MoS₂, MoS₂-NMP, MoS₂-PC, MoS₂-FA, MoS₂-EG, and MoS₂-DMSO.

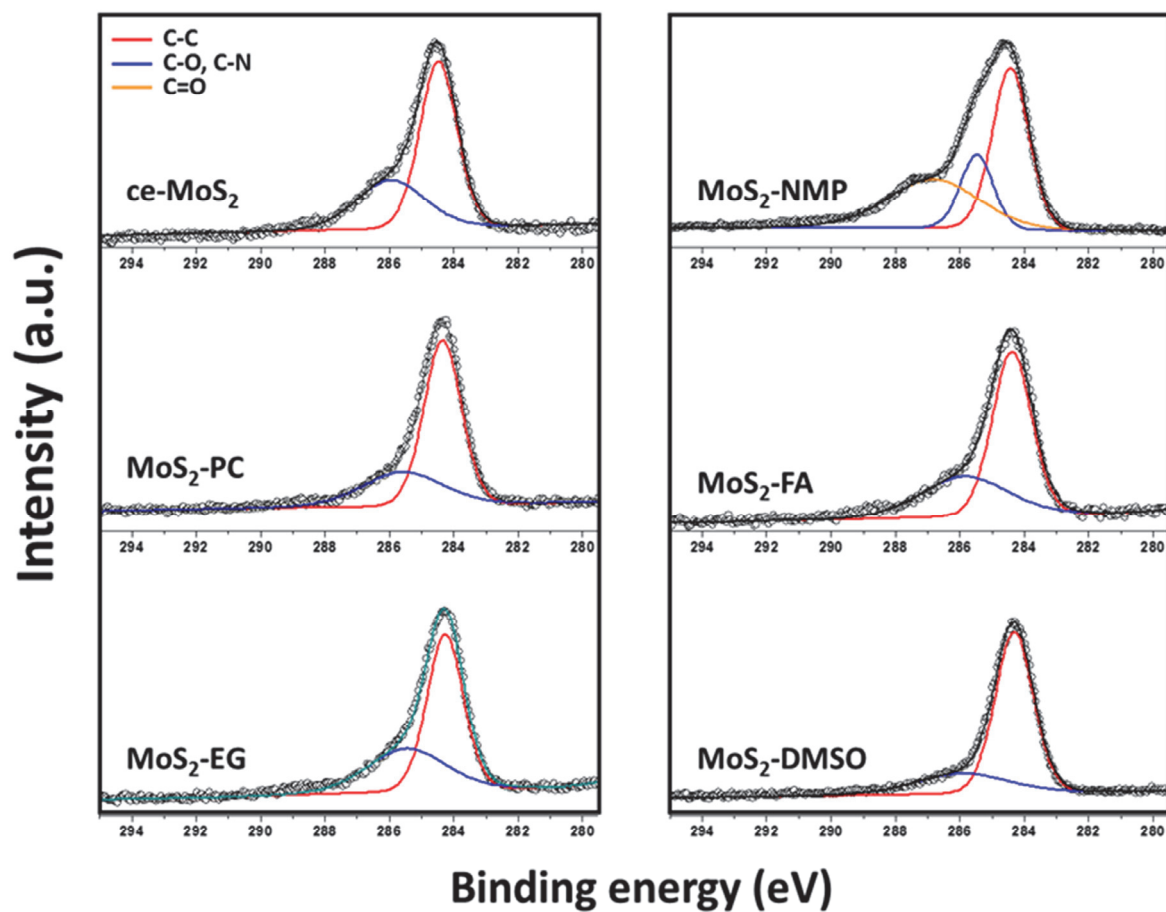


Figure S9. FT-IR spectra of the ce-MoS₂, MoS₂-NMP, and pure acetamide.

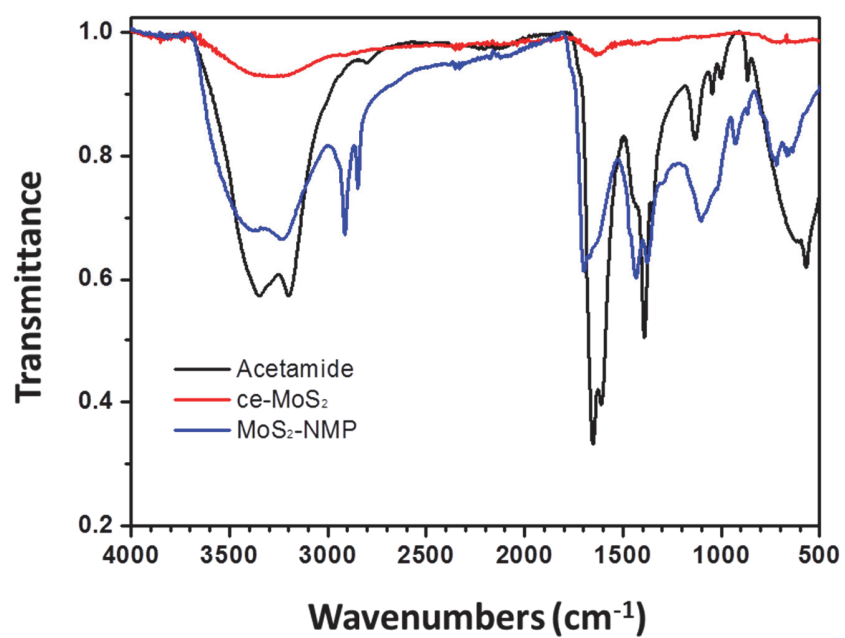


Figure S10. (a) Lambert-Beer plots to obtain the extinction coefficient value. (b) The extracted extinction coefficient values of as-prepared ce-MoS₂ and 2H-MoS₂ samples obtained by solvent thermal treatment (c) Concentration of 2H-MoS₂ in the supernatant of each dispersion as a function of storage time.

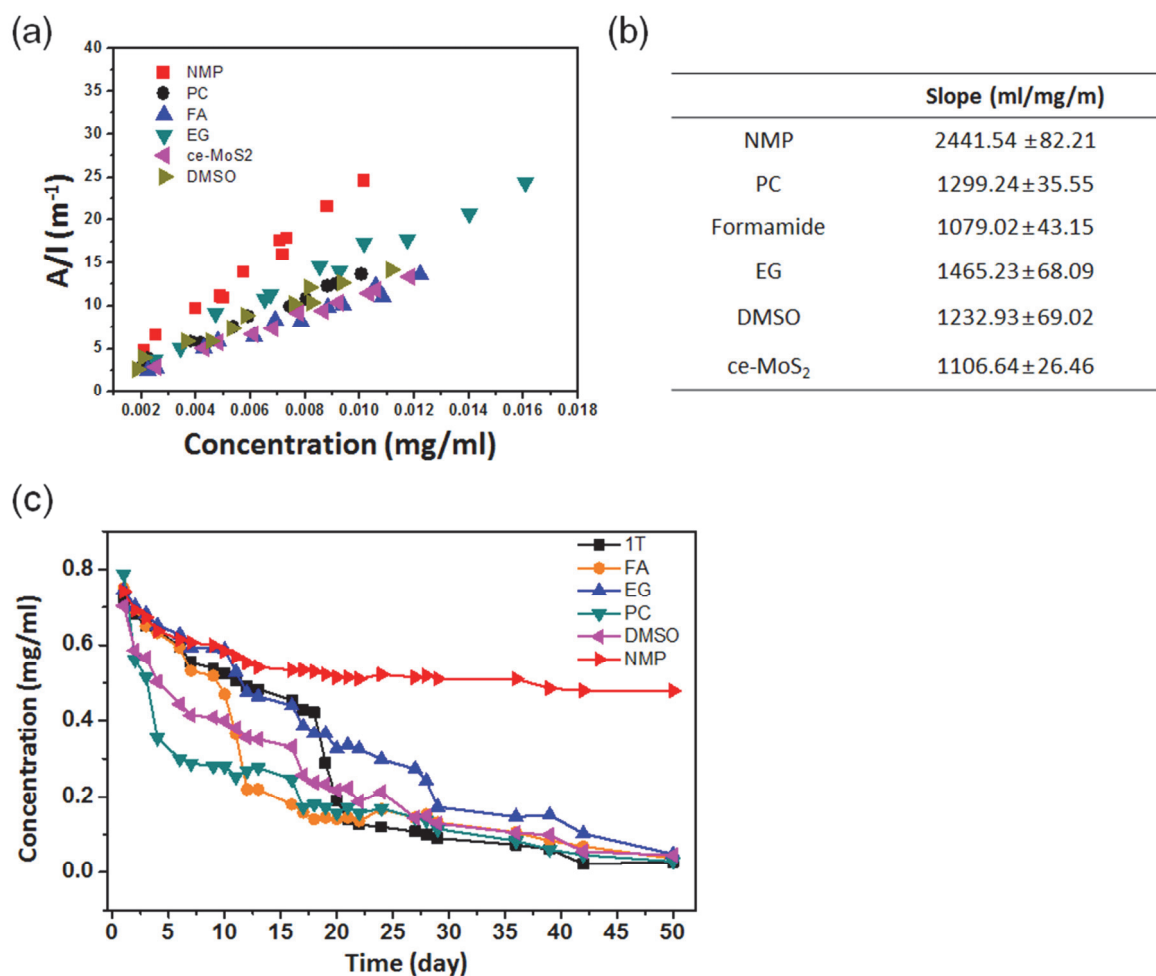


Table S3. Calculated concentration of MoS₂ in the supernatant of the aqueous dispersion as prepared and after 50 days.

	Concentration(mg/ml)	
	0 days	After 50 days
NMP	0.74219	0.47871
PC	0.74642	0.02966
FA	0.75070	0.03722
EG	0.78816	0.04874
DMSO	0.70338	0.04584
1T	0.72256	0.02731

Table S4. Zeta potential values of pristine 2H-MoS₂, exfoliated 1T-MoS₂ and functionalized MoS₂ (NMP)

Entry	Zeta potential (mV)
2H-MoS ₂ (bulk)	-20.2±0.48
1T-MoS ₂ (Exfoliated MoS ₂)	-43.1±0.64
MoS ₂ -NMP	-41.2±0.72

Figure S11. (a) Photographs of water contact angle taken after 2 s after dropping 1.5 μ l water on prepared MoS₂ thin films. (b) Sensitivity of humidity sensor based on ce-MoS₂, MoS₂-EG, and MoS₂-NMP at 80 relative humidity (RH) %

